Novel Strategy to Evaluate Platinum Photocatalysts for Hydrosilation-Curable Silicones

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1. Introduction

Release coatings are layers of cured silicone within pressuresensitive adhesives (PSAs), like stamps and labels, that are applied to material backings to protect the adhesive component before use. Hydrosilation, a type of reaction leveraged in the manufacture of release coatings, involves addition of a silane (Si-H) across an olefin (ex. vinyl group) and typically requires high temperatures. Photopolymerization is a low-temperature crosslinking process that is being explored as an environmentally conscious alternative.



Release coatings are commonly formed through Pt-catalyzed hydrosilation of hydrido- and vinyl-functionalized silicone fluids.



The authors of the plot below determined via RT-IR that, when incorporated into mixtures of the 3M catalyst (Pt-99) and silicone polymers PDMS-Vi and PMHS, some photosensitizers (ex. naphthalene) increased conversion and lowered the concentration of Pt required for photocuring. The Si-H stretching absorption band at 2165 cm⁻¹ was chosen to monitor conversion, while the Si-O-Si vibration at 1060 cm⁻¹ was used as an internal standard.



The photoactivated hydrosilation reaction was monitored via a novel ATR-FTIR strategy, enabling analysis of reaction kinetics in thin films. A "well" composed of six layers of electrical tape and one layer of double-sided tape with a hole punched through the stack was assembled and positioned to encircle the ATR crystal. A quartz microscope slide was placed on top to avoid evaporation of the sample contained by the well. Mixtures comprised of model silanes (MD^HM and DMS-V05), and Pt-catalysts (MeCpPtMe₃ and Cp*PtMe₃; 500 ppm Pt) with and without naphthalene were irradiated at a fixed distance with 365 and 400 nm light using LED sources in darkness for 5 minutes. The disappearance of the Si-H bending absorption band at 915 cm⁻¹ was followed, and referenced to the unchanging absorption band at 1260 cm⁻¹ attributed to the Si-C stretching vibration. Plots were generated that feature percent conversion as a function of time.



Catalyst	Experiment	Rate _i (×10 ⁻³ Ms ⁻¹)	k (×10 ⁻³ s ⁻¹)	% Conversion
MeCpPtMe3	365 nm, PS, 300s	3.01	1.98	96.8
MeCpPtMe3	365 nm, PS, 150s	2.09	1.38	95.3
MeCpPtMe ₃	365 nm, 300s	1.88	1.19	97.0
MeCpPtMe ₃	400 nm, PS, 300s	1.14	0.791	88.9
MeCpPtMe ₃	400 nm, 300s	0.417	0.108	34.7
Cp*PtMe ₃	365 nm, PS, 300s	1.39	1.00	96.0
Cp*PtMe ₃	365 nm, 300s	1.10	0.821	93.1
Cp*PtMe ₃	400 nm, 300s	0.864	0.627	79.4

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3. Future Work

Catalysts of the type $ArCpMePtMe_3$, where Ar = naphthyl, fluoronaphthyl, and methoxynaphthyl, are being investigated as they are hypothesized to accelerate photocatalytic curing due to the installment of ligands

containing light-harvesting "antennas". Eco-inspired innovation of the curing process will produce novel Pt(IV) photocatalysts that can be evaluated against the current benchmark using this method.



